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Growth of vertically aligned ZnO nanowalls for inverted polymer solar cells



Solar Energy Material

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ABSTRACT

This paper reports a facile fabrication of vertical ZnO nanowalls on ITO coated glass substrates by using an aqueous solution growth method at low temperature. The formation of nanowalls is ascribed to selective dissolution of (001) planes of the chemical bath deposited dense ZnO rods. The morphology of the etched ZnO nanowalls is determined by the structure of the as-grown ZnO rod arrays, which can be readily controlled by tuning aqueous solution parameters such as: initial pH value of chemical bath solution and the growth temperature. With verticaly aligned ZnO nanowalls as electrode in inverted polymer solar cells, the average performance of devices with open circuit voltage, short circuit current density, fill factor, and power conversion efficiency are measured as 0.56 V, 7.56 mW cm⁻², 0.49 and 2.14%, respectively. The results indicate that the two-dimensional structure of ZnO nanowalls can effectively serve as an electrode for inverted polymer solar cells.

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1. Introduction

Inverted polymer solar cells (PSCs) using n-type inorganic metal oxide nanostructures as electrode have attracted considerable attentions because of it has improved ambient device stability and compatibility to all solution roll-to-roll type fabrication onto flexible based substrates [1–5]. ZnO are particularly well-suited for this application because it has good transparency in the whole visible range, relatively high electron mobility, environment friendly and low-cost [6-9]. In addition, ZnO thin film can be easily processed via many methods at relatively low temperature, making ZnO fully compatible with fabrication onto flexible substrates [5,10–13]. It is known that the ZnO is the only material as cathode buffer layer that has been widely used in inverted PSCs and fabricated by roll-to-roll processing technique [14-16]. Recently, one dimensional (1D) ZnO nanostructures have attracted a lot of studies for applications in inverted PSCs [17-25]. The air stable vertically aligned 1D metal oxide could improve the performance of the inverted polymer solar cells by providing a short and continuous pathway for electron transport and might additionally contribute to enhancing the exciton dissociation ratio [19,24]. However, the solar cells with vertically aligned 1D ZnO nanostructures and P3HT:PCBM blend exhibited PCEs around

only 2%, with a few exceptions reached 3%–4% [21–25]. Ajuria et al. [24] had yielded a PCE up to 4.1% by improving the contact quality between ZnO and P3HT:PCBM layer and enhancing the ZnO/active layer interface area, which was obtained by using the ZnO nanoparticles modified ZnO nanowire arrays, a strong indication that a higher specific surface does promote the performance of the inverted PSCs. It has been demonstrated and explained that the performance of the inverted PSCs can be promoted by increasing the ZnO/active layer interface area [8,24,26].

ZnO nanowalls (NWs), as a two-dimensional (2D) nanostructure with larger surface area than 1D nanostructure, hold a high potential for application in inverted PSCs. The application of ZnO nanorods in inverted PSCs has attracted a lot of investigations. However, there is little or no report on the application of ZnO NWs in inverted PSCs. Recently, Shin et al. reported that the application of ZnO NWs as electron transport and hole block layers can enhance the PCE of inverted organic solar cells due to the increase in the charge transport interface area [27]. Our work will evidently serve three purposes: (1) supporting and verifying this most recent publication, (2) offering an alternative morphology and possibly different surface chemistry, and (3) promising a further study on the manipulation of morphology and better fundamental understanding.

Because the ZnO NWs have high potential for application in many fields, such as: energy-storage devices [28], biological sensors [29,30], and filed emission (FE) [31], in the past decade, the ZnO NWs structures have been achieved by many methods at

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high growth temperature (500 °C–1100 °C) under vacuum and/or with catalyst [28–30,32–36]. High growth temperatures limit the applicable substrate materials, such as the transparent conducting oxides (TCOs) substrates which are usually used as transparent electrodes in the application of photovoltaics and opto-electronics devices, since the conductivity of TCO usually decays rapidly at high annealing temperatures of above 500 °C [37]. Recently, the electrochemical deposition [31,38,39] and several kinds of aqueous solution methods [40–43] have been employed to prepare ZnO NWs. Although these methods can produce ZnO NWs by solution-based approaches at low temperature, tedious growth procedures or special substrates, such as GaN and Si-wafer are commonly required.

In this regard, in this work, we demonstrate a simple aqueous solution fabrication of the high density vertically aligned ZnO NWs on indium-doped tin oxide (ITO) substrates by selective-etching the dense ZnO rods. The method presented here offers several advantages, such as low growth temperature, catalyst-free, and potentially low-cost manufacturing. The ZnO NWs growth on ITO substrates at low-temperature hold promise for applications in both inverted PSCs and hybrid solar cells. As a preliminary application, the inverted PSCs based on ZnO NWs was constructed and investigated.

2. Experimental section

2.1. Materials

Zinc acetate dehydrate (99.0%), zinc nitrate hexahydrate (99.0%), 2-methoxy ethanol (99.0%), monoethanolamine (99.0%), hexamethylenetetramine (HMT, 99.0%) and potassium hydroxide (KOH) were purchased from Sigma-Aldrich and used as received without further purification. Regio-regular poly(3-hexylthiophene) (P3HT, 4002-E grade) was purchased from Rieke Metals, Inc. Methyl [6,6]-phenyl-C60-butyrate (PCBM, 99.0% purity) was purchased from American Dye Source Inc., Canada. The poly(3,4-ethylene-dioxylene thiophene)–poly(styrene sulfonic acid) (PEDOT:PSS, Clevios 4083) was purchased from H.C. Starck. The ITO coated glasses (Colorado Concept Coatings LLC, 10–15 Ω sq⁻¹) were cleaned prior to use by ultrasonic agitation in a detergent solution, deionized (DI) water, acetone and isopropanol and then dried in air.

2.2. Preparation of ZnO nanowalls

ZnO nanowalls (NWs) were grown using a three-step method: spin-coating ZnO seeds on the ITO substrates, aqueous solution growth of ZnO rods and the selective-etching to form ZnO NWs. The ZnO seed layers were prepared by spinning coat a sol-gel with concentration of zinc acetate 0.1 M on the ITO substrates (10-15 Ω sg⁻¹), which has been described in our previous work [44]. Subsequently, the growth of ZnO rods were carried out by suspending the substrates coated with ZnO seed in a beaker filled with an equimolar aqueous solution of 0.1 M zinc nitrate hexahydrate $(Zn(NO_3)_2 \cdot 6H_2O)$, and 0.1 M methenamine $(C_6H_{12}N_4, HMT)$ at 75 °C for 3 h in water bath, the initial pH value of the solution was adjusted by adding CH₃COOH. The resultant substrates were removed from the solution, rinsed with DI water and then immersed into 0.3 M KOH aqueous solution at 80 °C for 15 min in water bath. Finally, the substrates were rinsed by DI water and then dried in oven at 80 °C for 1 h. The ZnO NWs, before used to prepare the inverted polymer solar cells, were further annealed at 350 °C for 20 min in air.

2.3. Device fabrication

Firstly, a PCBM interlayer was spin-coated from a dichloromethane solution containing 20 mg ml⁻¹ of PCBM onto the ZnO NWs at 1000 rpm for 30 s. After that, the samples were baked at 250 °C for 1 min to drive away residual solvent and assisting the PCBM contact with ZnO NWs. Huang et al. [23] demonstrated and explained that the PCBM layer between ZnO NW and active layer could improve the infiltration of the active polymer layer into the gaps between ZnO nanorods. Similarly, we introduced a layer of PCBM between ZnO NWs and active laver to help the infiltration of the active layer into ZnO NWs spacing. Secondly, the chlorobenzene blend solution of P3HT:PCBM containing (20 mg ml⁻¹) P3HT and (16 mg ml⁻¹) PCBM was spin coated onto the PCBM layer at 1000 rpm for 30 s. Then the samples were baked at 225 °C for 1 min to help the self-organization of P3HT, as well as driving away residual solvent and assisting the polymer infiltrate into the ZnO NWs [45]. Thirdly, a diluted PEDOT:PSS solution was subsequently spin-coated onto the P3HT:PCBM layer to form hole-transport layer. The devices were then baked at 120 °C for 10 min. At last, a 100 nm thick Ag top electrode film was deposited under a vacuum of 5×10^{-7} Torr. The size of the solar cells prepared on ITO substrates is \sim 2.25 cm² and the size of each Ag electrode is 3.14 \times 10⁻⁶ m².

2.4. Characterization

The surface morphology of the specimens was characterized by scanning electron microscopy (SEM, Philips, JEOL JSM7000). The phase composition of the samples was characterized by X-ray diffraction (XRD, Philips PW 1830 diffractometer with Ni-filtered Cu-*K* α source (λ = 1.5405 Å) radiation). The *J*–*V* characteristics of the solar cells were tested in glovebox using a Keithley 2400 source measurement unit, and an Oriel Xenon lamp (450 W) coupled with an AM1.5 filter. A silicon solar cell certificated by the NREL was used as reference to calibrate the measurement condition. The light intensity of 100 mW cm⁻² was used in this work.

3. Results and discussions

Fig. 1 shows the SEM images of the ZnO seed layer, as-grown dense ZnO rods, etched ZnO nanowalls (NWs) and the crosssection of the NWs. Fig. 1(A) reveals that the ZnO seed layer consists of uniform and densely packed particles with diameters around 10 nm. The high quality closely packed ZnO seed layer is crucial to achieve *c*-axis oriented ZnO rod arrays with controlled density and dimension through evolution selection growth in aqueous solution. Fig. 1(B) displays that the as-grown dense ZnO rods film consisting of dense and plate-like crystals, where the rods are packed so closely that most of the side walls of rods are grown together. Fig. 1(C) presents that the ZnO NWs are vertical to the substrate and the inset of a high mangnified SEM image reveals the walls thickness are around 50 nm. Fig. 1(D) indicats the cross-section of the ZnO NWs.

In this work, we suggest that the growth of dense ZnO rods film should result from the following several reasons. Firstly, the samll and densely packed particles in ZnO seed layer (Fig. 1(A)) will result in the growth of ZnO rods with high density. Secondly, both the high concentration (0.1 M) of Zn^{2+} in the aqueous solution and the low growth temperature (75 °C) will also lead to the growth of ZnO rods with increased diameters, and thus result in the growth of dense ZnO rods film. Thirdly, the low pH value is also an important factor for increasing crystal size of ZnO nanostructures grown from aqueous solution route. For the zinc nitrate hexahydrate–HMT aqueous solution system, the decrease of pH value produces a decrease in supersaturation and consequently a decrease of the nucleation Download English Version:

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